

# PHOTOCONDUCTIVE DECAY LIFETIME AND SUNS- $V_{oc}$ DIAGNOSTICS OF EFFICIENT HETEROJUNCTION SOLAR CELLS

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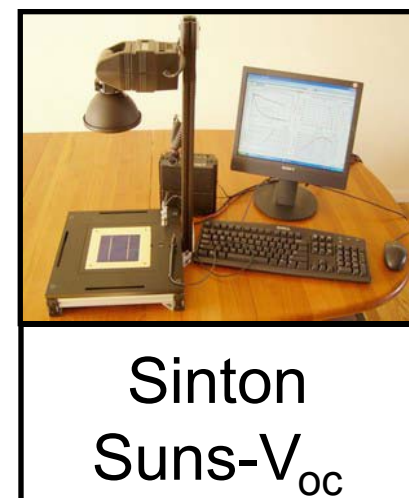
## Introduction

### Techniques for Optimization of Si heterojunction (SHJ) solar cells



Sinton Lifetime Measurement

1. Photoconductive decay technique
  - Non-contact
2. Can measure lifetime after a-Si:H deposition
  - Amorphous silicon (a-Si:H) excellent surface passivation
  - Surface recombination velocity <15 cm/s
3. Reliable Transient Mode Lifetime and Implied  $V_{oc}$



Sinton  
Suns- $V_{oc}$

Sinton Suns- $V_{oc}$  Measurement Apparatus

1. Rapid Flash Lamp Technique
2. Can be performed after ITO deposition
3. Reliable  $V_{oc}$  data before contacts & finished cell
  - Troubleshoot shunting, series resistance finished cells

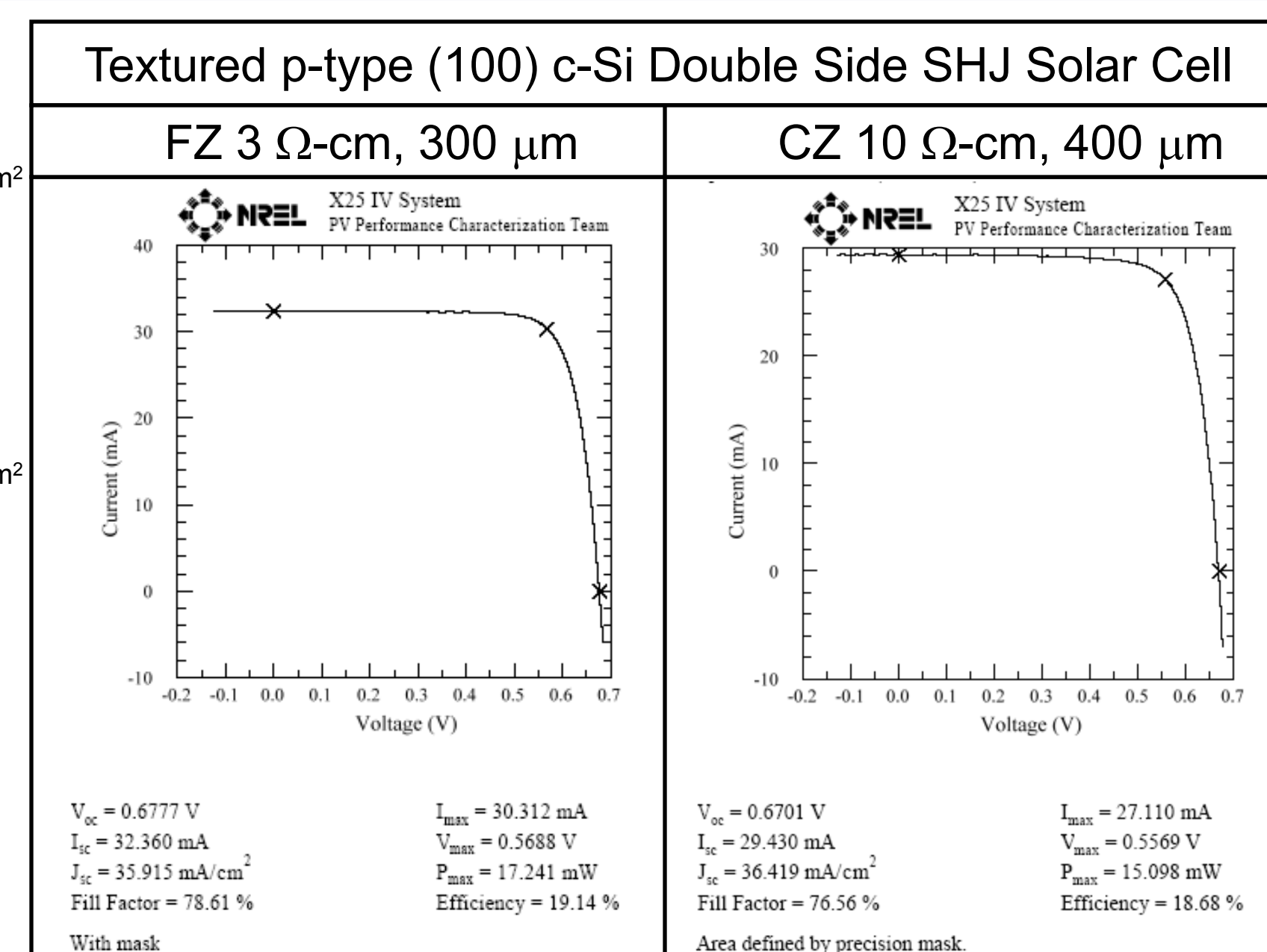
## Confirmed Light I-V FZ and CZ

**Best p-FZ**

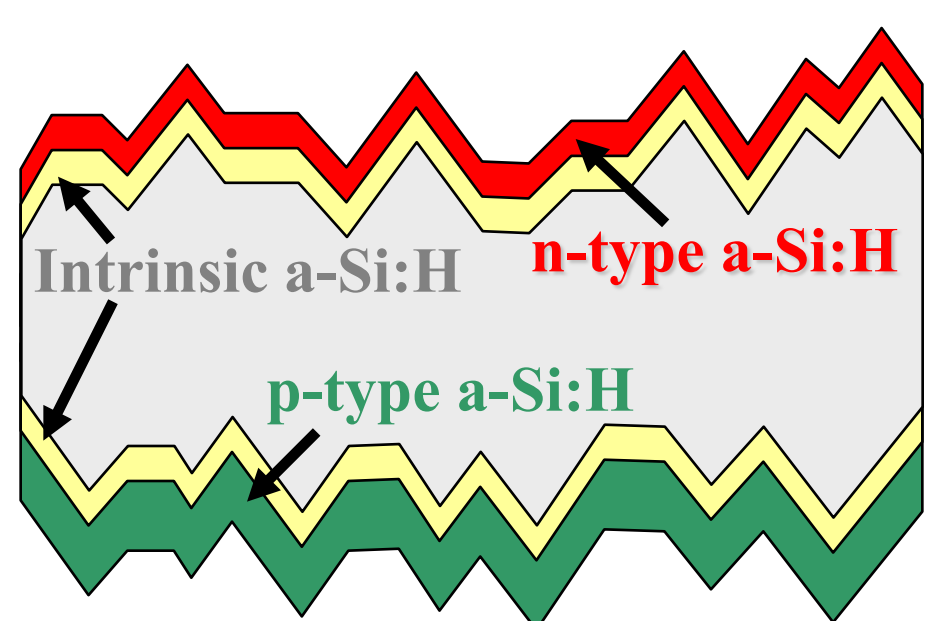
$V_{oc}$  = 678 mV  
 $J_{sc}$  = 35.9 mA/cm<sup>2</sup>  
FF = 78.6%  
 $\eta$  = 19.1%

**Best p-CZ**

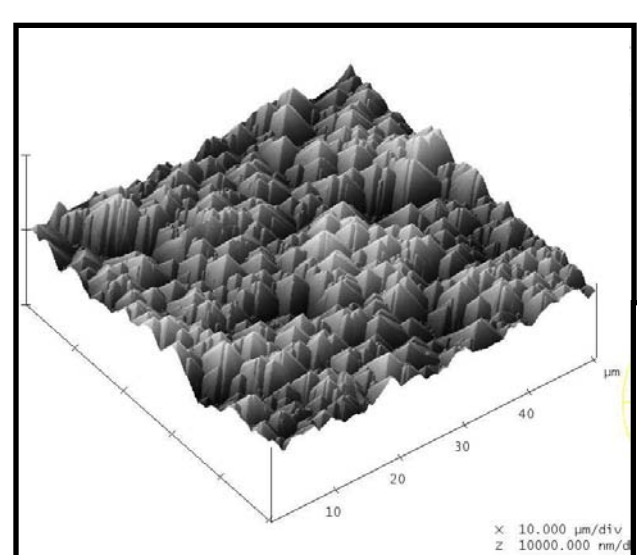
$V_{oc}$  = 670 mV  
 $J_{sc}$  = 36.4 mA/cm<sup>2</sup>  
FF = 76.6%  
 $\eta$  = 18.7%



## 1: Heterojunction Deposition

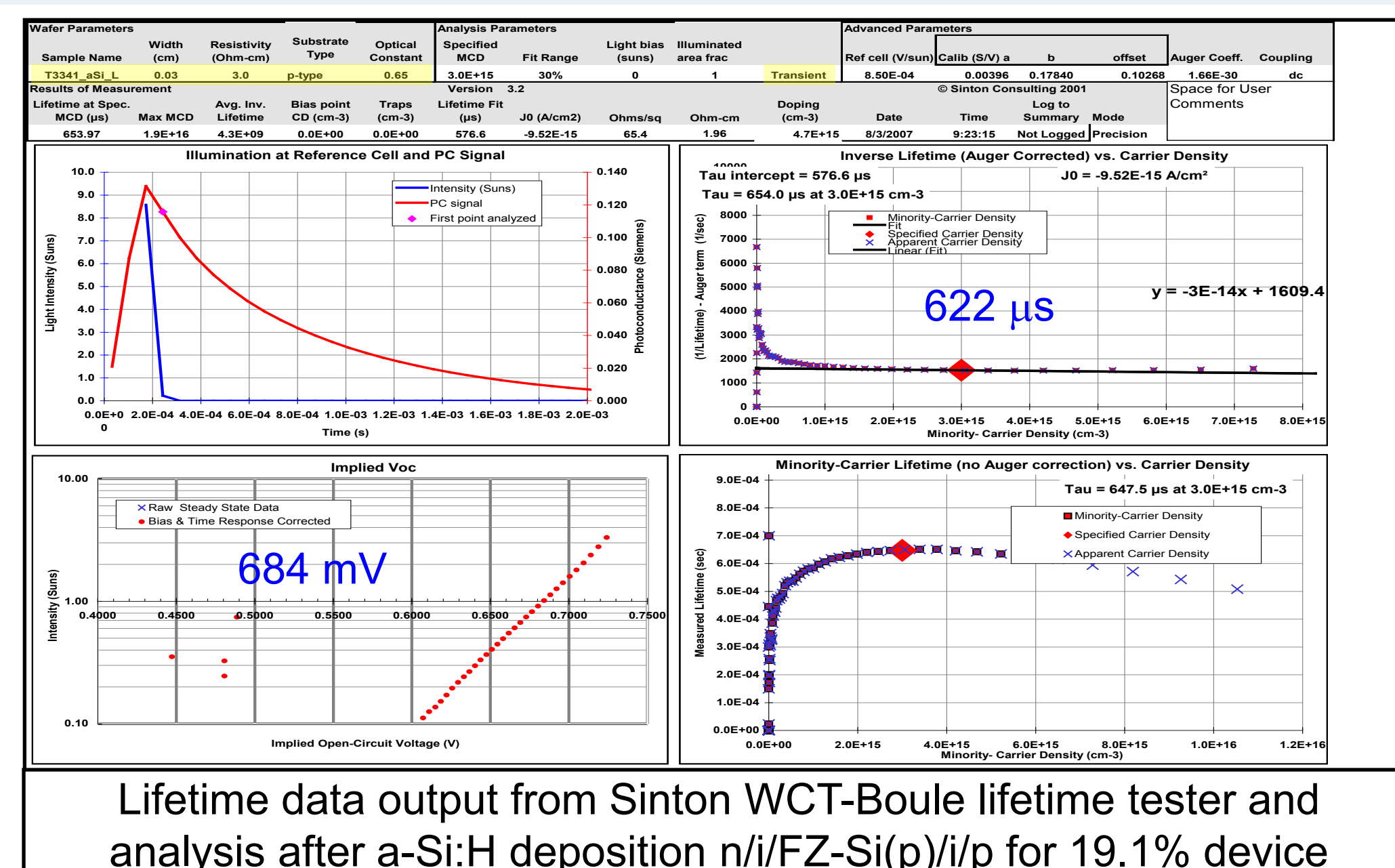


- Isotropic texturing and standard clean (RCA)
- Strip protective chemical oxide 24:1 DI H<sub>2</sub>O and (49%)HF
- Deposit front emitter
  - 3 nm a-Si:H(i): 100°C
  - 4-5 nm a-Si:H(n): 200°C
- Deposit base contact
  - 3 nm a-Si:H(i): 100°C
  - 5-20 nm a-Si:H(p): 250°C

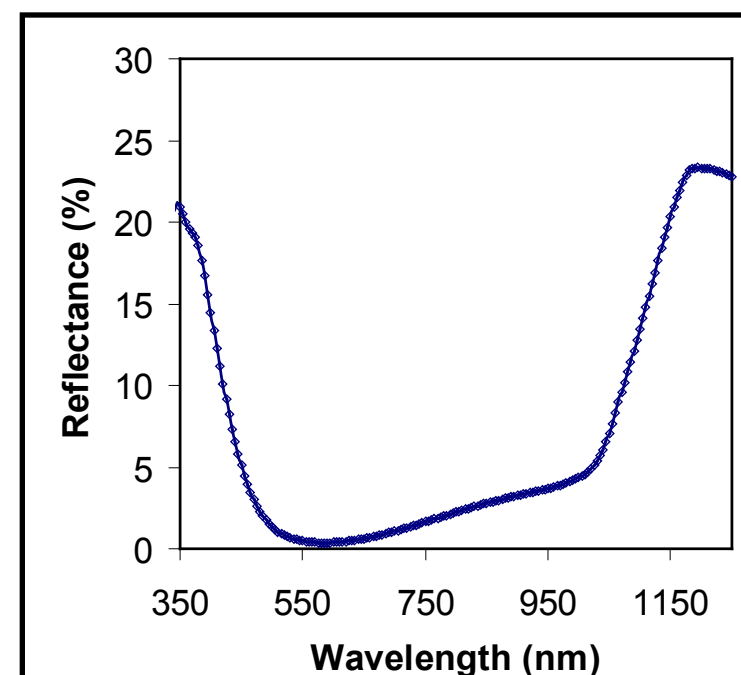
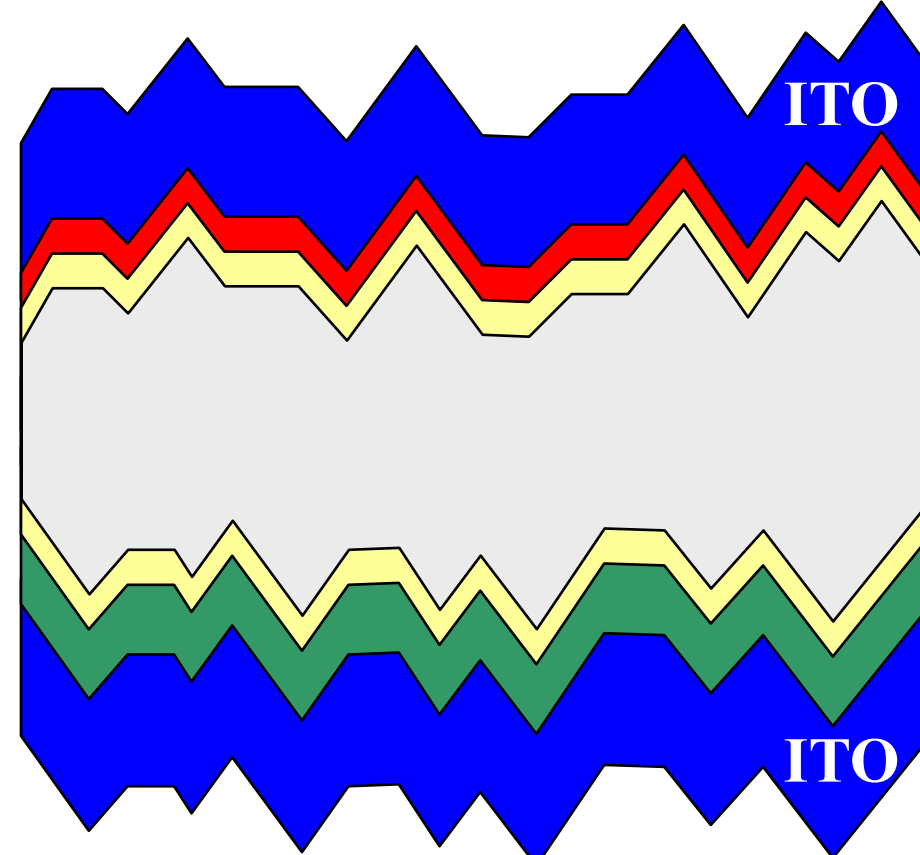


AFM measurement of as textured Silicon wafer

## Lifetime Measurement: a-Si:H/c-Si

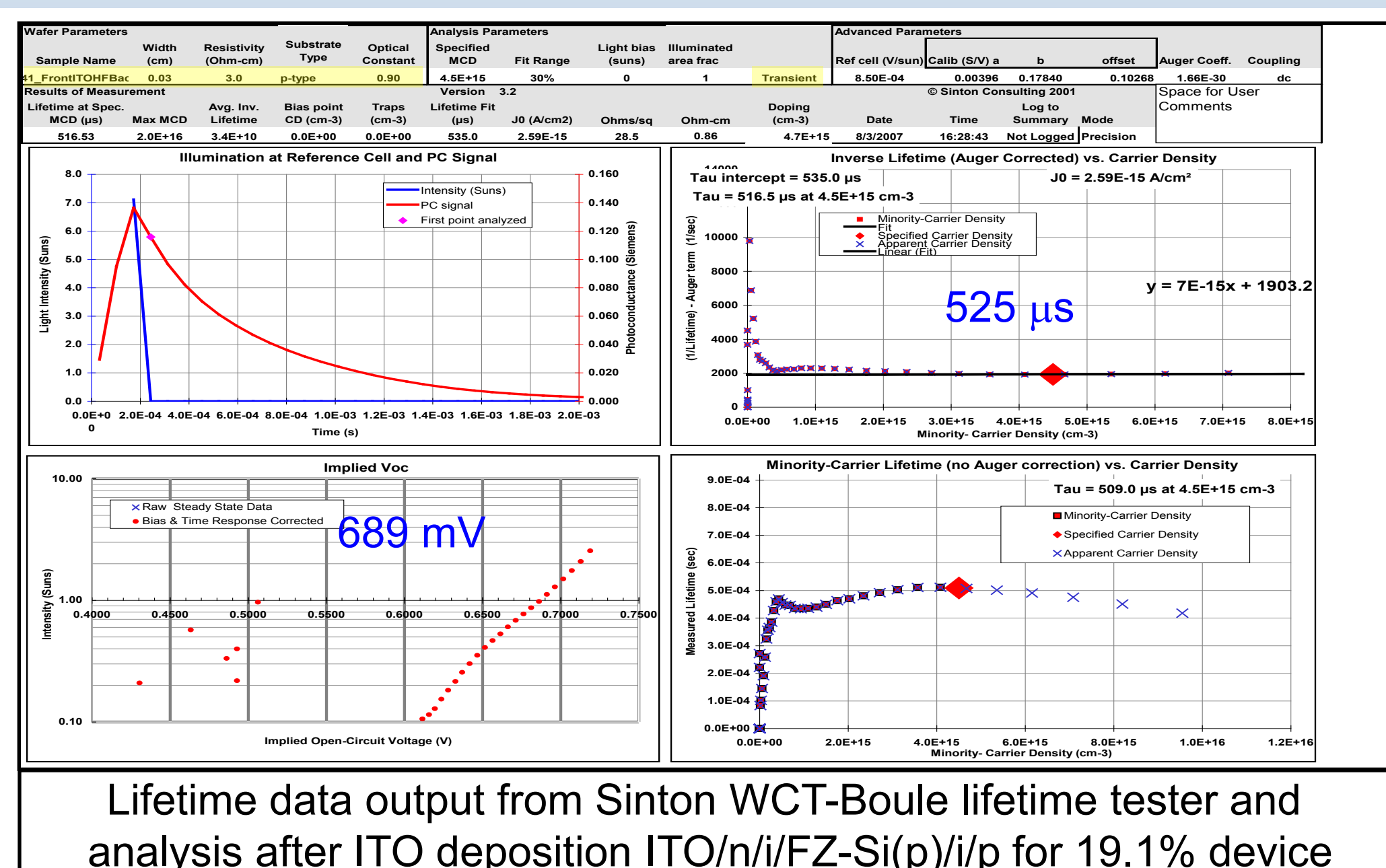


## 2: ITO Deposition



Typical reflectance curve for textured c-Si coated with ITO, no back metal

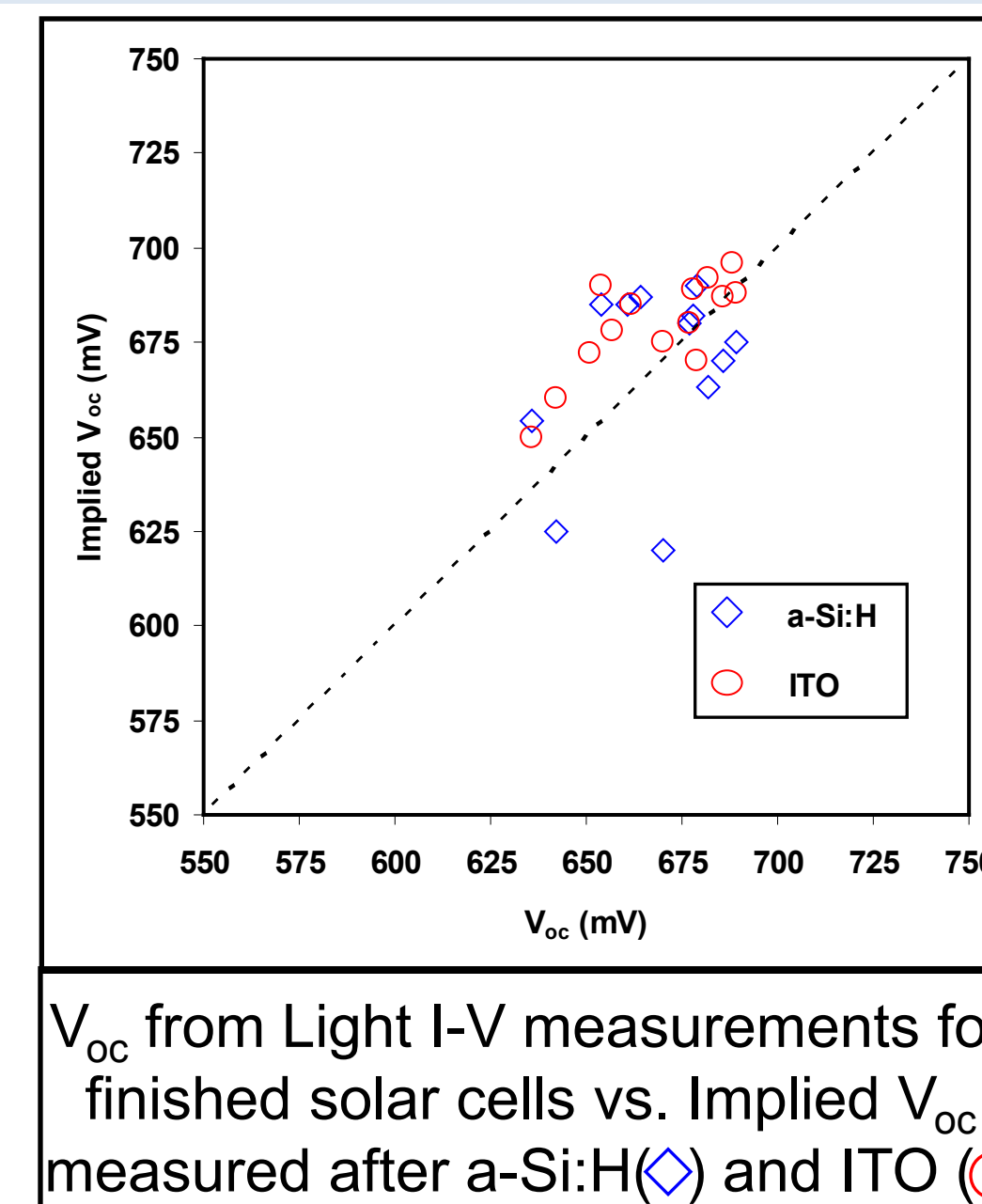
## Lifetime Measurement: ITO/a-Si:H/c-Si



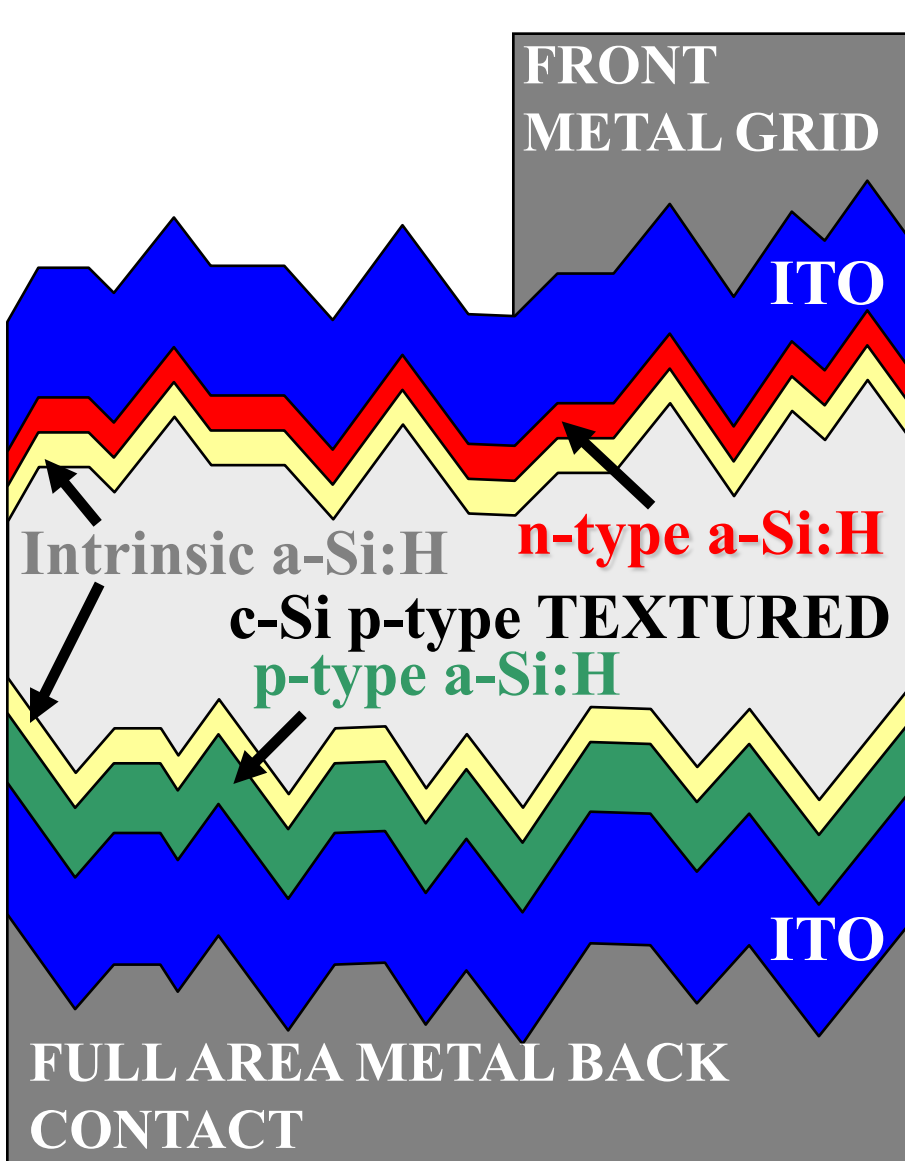
## Lifetime Derived Implied $V_{oc}$ : a-Si:H & ITO

### Potential Cell Performance vs. Actual Cell $V_{oc}$

1. Lifetime is an average over whole measurement area
  - Infrared filter (RG-850)
2. Aperture mask for Light I-V
  - $V_{oc}$  of defined cell area
3. Figure shows good passivation of SHJ on c-Si
  - Grouping of cells between 650-690 mV

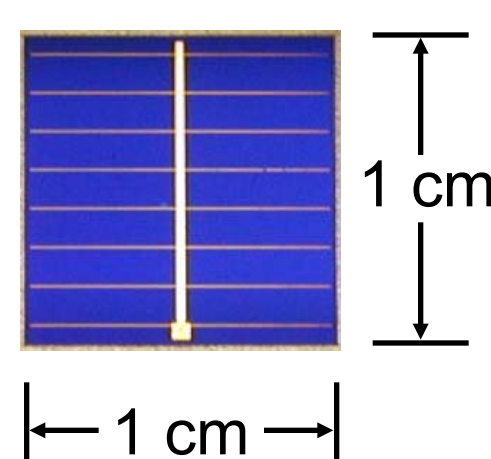


## 3: Finished SHJ Solar Cell



**Metal Contacts**

- e-Beam PVD : Ti/Pd/Ag/Pd 50nm/60nm/4-5 $\mu$ m/60nm Back then Front
- or
- e-Beam PVD : Al on a-Si:H(p) Metal Back Contact 1  $\mu$ m : RT



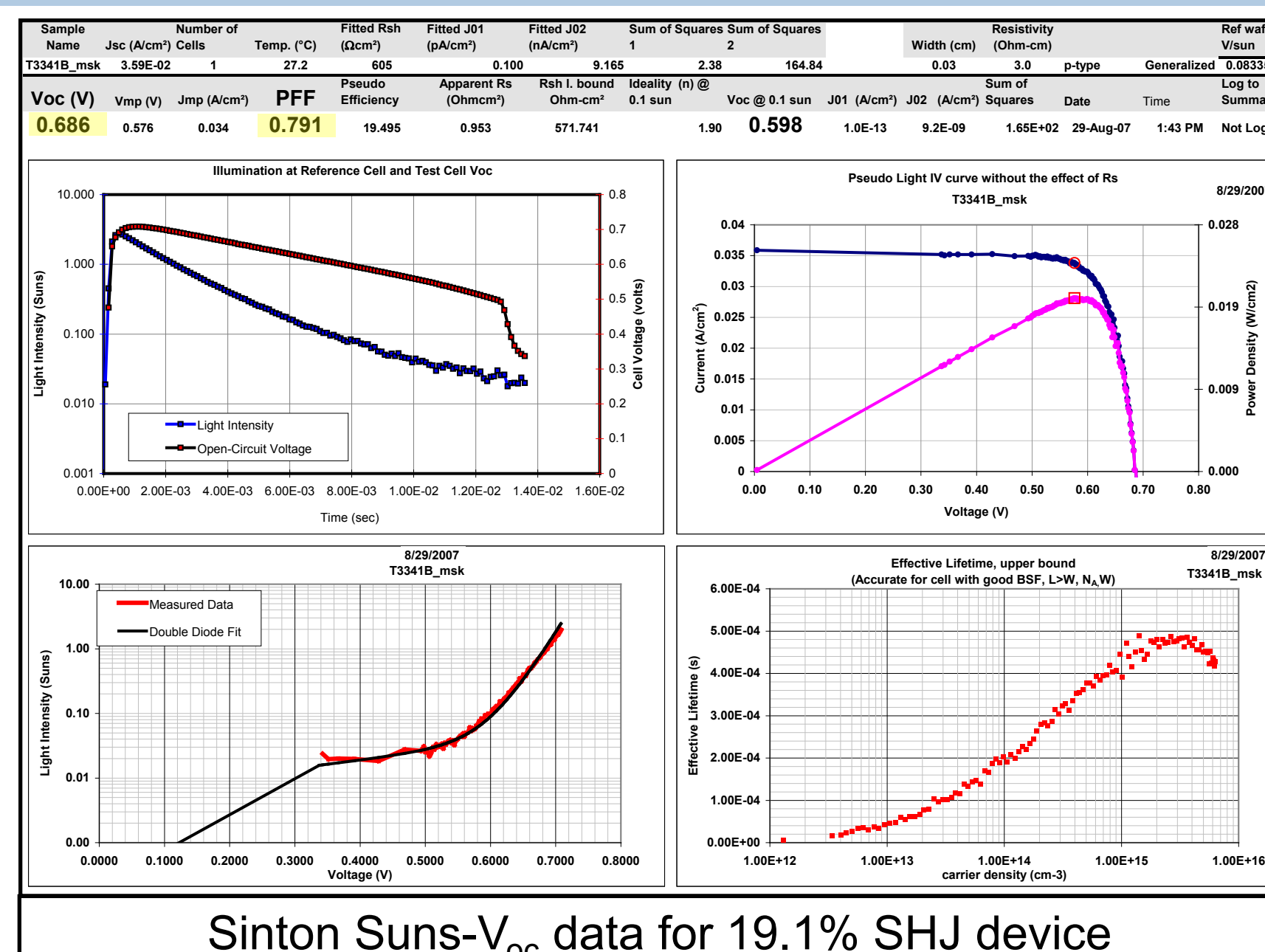
## Finished SHJ Solar Cell: Suns- $V_{oc}$

**Best p-FZ**

$V_{oc}$  = 686 mV

**Pseudo FF**

79.1%

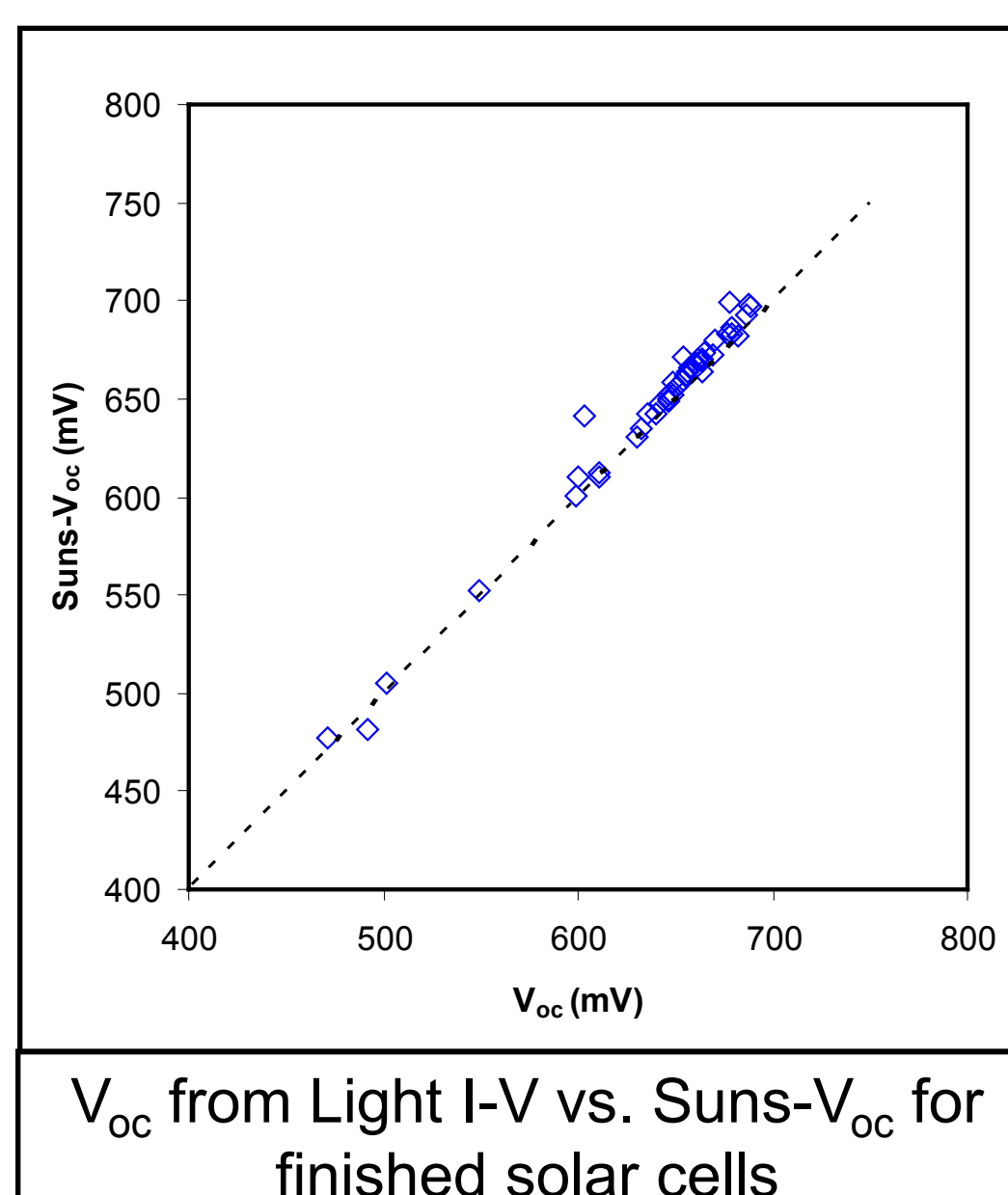


## Finished SHJ Solar Cell Comparisons

### Potential Cell Performance vs. Actual Solar Cell $V_{oc}$

- Sometimes Suns- $V_{oc}$  greater than Light I-V  $V_{oc}$
- Flash vs. Simulator lamp
  - Temperature control

Good agreement between AM1.5 LIV  $V_{oc}$  and Suns- $V_{oc}$



## Conclusions

### PCD Lifetime

- Fast non-contact measurement
- Enabled by excellent surface passivation of a-Si:H on c-Si
- Implied  $V_{oc}$  is a good parameter to infer final device performance

### Suns- $V_{oc}$ measurement

- For SHJ devices Suns- $V_{oc}$  can be measure before metal contacts
- For finished devices combined with AM1.5 Light I-V can extract series resistance of metal contacts to solar cell

These tools have sped up optimization of p-type SHJ processes yielding efficiencies of 19.1% for float-zone and 18.7% for Czochralski silicon.

